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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
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10/731,453

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Rajeev Joshi

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27966

7590

07/16/2008

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EXAMINER

ZARNEKE, DAVID A

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PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Office Action Summary	Application No. 10/731,453	Applicant(s) JOSHI ET AL.	
	Examiner David A. Zarneke	Art Unit 2891	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 30 April 2008.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 47-72 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 47-72 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
 - ☐ Certified copies of the priority documents have been received in Application No. _____.
 - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | Paper No(s)/Mail Date. _____ |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08) | 5) <input type="checkbox"/> Notice of Informal Patent Application |
| Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 4/30/08 has been entered.

Response to Arguments

Applicant's arguments filed 4/30/08 have been fully considered but they are not persuasive. Five (5) arguments were presented with respect to the previous office action.

The first argument is that the Office can't substantiate the combination of references suggest an RDL on the chip pad.

Please note that the rejection relies upon the AAPA figures 1-3 from applicant's own specification to teach a RDL on a chip pad. Therefore, the rejection has substantiated the references teach a RDL on a chip pad.

The next argument is that the Office can't substantiate the combination of references suggest an insulating layer containing a non-polymeric material that covers only a portion of the RDL pattern.

Please note that while the AAPA is silent as to the specific material used as the insulating layer that covers the RDL, the use of a non-polymeric insulator would have been obvious to one of ordinary skill in the art because insulating layers are known to be made of both polymeric and non-polymeric materials, such as silicon dioxide, are commonly known generic materials used as insulating layers. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Third, it is argued that the Office can't substantiate the combination of references suggest a stud bump on the uncovered portion of the RDL.

Please note that the AAPA figures 1-3 teach a stud bump on the uncovered portion of the RDL. Therefore, the rejection has substantiated the references teach a stud bump on the uncovered portion of the RDL.

The fourth argument is that the Office hasn't shown the combination of references suggest the conductive particles comprise a metal with an insulating layer. This argument goes on to state that even though Kaneda teaches conductive particles comprise a metal with an insulating layer, Kaneda says that it isn't needed.

Please note that Kaneda clearly recites conductive particles comprise a metal with an insulating layer, as relied upon in the rejection. Further note that Kaneda doesn't actually state that this isn't needed. All that Kaneda states that an insulating matrix resin ensures anisotropic conductivity in the direction of contact bonding (5, 1+) and this anisotropic conductivity is improved by using particles of a particular diameter (6, 40+). Kaneda goes on to further state that insulating properties in the lateral direction are improved by using conductive particles comprising a metal with an

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insulating layer (6, 35+). Note the anisotropic conductivity and the insulating properties are different variables that Kaneda controls by using different techniques.

Finally, it is argued that the Office hasn't shown the combination of references suggest the stud bump comprises Cu because no evidence has been provided to support the contention that Cu can form eutectic alloys.

Please note that the rejection didn't state anything relating to the ability of Cu to form eutectic alloys. The rejection stated that Cu and Au are equivalent materials used as bumps.

Claim Objections

Claim 72 is objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim. Applicant is required to cancel the claim(s), or amend the claim(s) to place the claim(s) in proper dependent form, or rewrite the claim(s) in independent form. Claim 72 is a duplicate of claim 69.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

The factual inquiries set forth in *Graham v. John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

1. Determining the scope and contents of the prior art.
2. Ascertaining the differences between the prior art and the claims at issue.
3. Resolving the level of ordinary skill in the pertinent art.
4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

Claims 47-54 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Admitted Prior Art (hereafter AAPA) Figures 1-3, in view of Shibata, US Patent 6,461,890 and Kaneda et al., US Patent 6,223,429.

AAPA teaches a wafer-level chip scale package, comprising:
a substrate [5] containing a chip pad [40];
a re-distributed line (RDL) pattern [20] on the chip pad;
an insulating layer [25] covering a portion of the RDL pattern;
a stud bump [35] located on the portion of the RDL pattern not covered by the insulating layer.

AAPA fails to teach a leadframe substrate containing a bond pad; and
an adhesive material containing conductive particles located between the chip and the substrate.

Shibata (Figures 5 & 6) teaches:

- a chip [10] containing a stud bump [11];
- a leadframe substrate [60] containing a bond pad [61]; and

an adhesive material [30] containing conductive particles [32] located between the chip and the substrate.

It would have been obvious to one of ordinary skill in the art at the time of the invention to use the leadframe with the claimed conductive adhesive because it is conventionally known in the art to connect a chip to a leadframe using a conductive adhesive. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Further, AAPA and Shibata fail to teach the conductive particles comprise metal with an insulating layer.

Kaneda (6, 35+) teaches the conductive particles comprise metal with an insulating layer.

It would have been obvious to one of ordinary skill in the art at the time of the invention to use the conductive particles of Kaneda in the invention of Shibata because Kaneda teaches conductive particles comprising metal with an insulating layer improves insulating properties in the lateral direction of metal particles (6, 35+).

Lastly, AAPA, Shibata and Kaneda fail to teach the insulating layer comprises a non-polymeric dielectric material.

AAPA is silent as to the specific material used as the insulating layer that covers the RDL, the use of a non-polymeric insulator would have been obvious to one of ordinary skill in the art because insulating layers are known to be made of both polymeric and non-polymeric materials, such as silicon dioxide, are commonly known

generic materials used as insulating layers. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Regarding claim 48, Shibata teaches at least one conductive particle is located between the stud bump and the bond pad (figure 6).

With respect to claim 49, Shibata teaches the adhesive material comprises an anisotropic conductive film, an anisotropic conductive paste, or an isotropic conductive paste (7, 64+).

As to claim 50, Shibata, which teaches the bump is made of gold (7, 45+), teaches the package does not contain any solder paste.

In re claim 51, while Shibata, which teaches the use of gold (Au) bumps (7, 45+), fails to teach the stud bump comprises Cu, it would have been obvious to one of ordinary skill in the art at the time of the invention to use Cu in the invention of Shibata because Au and Cu are materials known to a skilled artisan to be equivalent. Both are well known in the art materials used as bumps, as taught by Tummala et al., Microelectronics Packaging Handbook: Semiconductor Packaging - Part II, 1997, pp II-207. The substitution of one known equivalent technique for another may be obvious even if the prior art does not expressly suggest the substitution (Ex parte Novak 16 USPQ 2d 2041 (BPAI 1989); In re Mostovych 144 USPQ 38 (CCPA 1964); In re Leshin 125 USPQ 416 (CCPA 1960); Graver Tank & Manufacturing Co. V. Linde Air Products Co. 85 USPQ 328 (USSC 1950).

Regarding claim 52, AAPA, Shibata and Kaneda fail to teach the stud bump is formed by wire bonding a Pd coated copper wire to the RDL pattern using a capillary to provide the stud bump with a coined shape.

Please note that using by wire bonding a Pd coated copper wire to the RDL pattern using a capillary to provide the stud bump is a process limitation is a product claim and therefore isn't given any patentable weight. Even though product-by-process claims are limited by and defined by the process, determination of patentability is based on the product itself. The patentability of a product does not depend on its method of production. If the product in the product-by-process claim is the same as or obvious from a product of the prior art, the claim is unpatentable even though the prior product was made by a different process." In re Thorpe, 777 F.2d 695, 698, 227 USPQ 964, 966 (Fed. Cir. 1985)

Further, relating to the coined shape, while Shibata fails to teach the stud bump is a coined stud bump, it would have been obvious to one of ordinary skill in the art at the time of the invention to use a coined stud bump in the invention of Shibata because the use of a stud bump or a coined stud bump are equivalent. A skilled artisan knows that each are commonly known and used bumps to interconnect a die to a substrate, as taught by Lau, Flip Chip Technologies, 1996, pp. 129-131. The substitution of one known equivalent technique for another may be obvious even if the prior art does not expressly suggest the substitution (Ex parte Novak 16 USPQ 2d 2041 (BPAI 1989); In re Mostovych 144 USPQ 38 (CCPA 1964); In re Leshin 125 USPQ 416 (CCPA 1960);

Graver Tank & Manufacturing Co. V. Linde Air Products Co. 85 USPQ 328 (USSC 1950).

With respect to claim 53, while AAPA fails to teach the insulating layer comprises silicon nitride, silicon oxide, or silicon oxynitride, it would have been obvious to one of ordinary skill in the art at the time of the invention to use silicon nitride, silicon oxide, or silicon oxynitride as the insulating layer in the invention of AAPA because they are conventionally known and used insulating layers known to each and every skilled artisan. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

As to claim 54, while AAPA fails to teach there is no under bump metal under the stud bump, it would have been obvious to one of ordinary skill in the art at the time of the invention to remove the UBM of AAPA because the omission of an element and its function is obvious if the function of the element is not desired (MPEP 2144.04 IIA). The device would work without the UBM, therefore it would be obvious to remove it and its desired function in order to reduce cost.

Claims 55-61 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Admitted Prior Art (hereafter AAPA) Figures 1-3, in view of Shibata, US Patent 6,461,890 and Kaneda et al., US Patent 6,223,429.

AAPA teaches a wafer-level chip scale package, comprising:

- a substrate [5] containing a chip pad [40];
- a re-distributed line (RDL) pattern [20] on the chip pad;
- an insulating layer [25] covering a portion of the RDL pattern;

a stud bump [35] located on the portion of the RDL pattern not covered by the insulating layer.

AAPA fails to teach a leadframe substrate containing a bond pad; and
an adhesive material containing conductive particles located between the chip and the substrate.

Shibata (Figures 5 & 6) teaches:
a chip [10] containing a stud bump [11];
a leadframe substrate [60] containing a bond pad [61]; and
an adhesive material [30] containing conductive particles [32] located between the chip and the substrate.

It would have been obvious to one of ordinary skill in the art at the time of the invention to use the leadframe with the claimed conductive adhesive because it is conventionally known in the art to connect a chip to a leadframe using a conductive adhesive. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Further, AAPA and Shibata fail to teach the conductive particles comprise metal with an insulating layer with an insulating layer with at least one conductive particle contacting both the stud bump and the bond pad.

Kaneda (6, 35+) teaches the conductive particles comprise metal with an insulating layer with at least one conductive particle contacting both the stud bump and the bond pad.

It would have been obvious to one of ordinary skill in the art at the time of the invention to use the conductive particles of Kaneda in the invention of Shibata because Kaneda teaches conductive particles comprising metal with an insulating layer improves insulating properties in the lateral direction of metal particles (6, 35+).

Also, AAPA, Shibata and Kaneda fail to teach the insulating layer comprises a non-polymeric dielectric material.

AAPA is silent as to the specific material used as the insulating layer that covers the RDL, the use of a non-polymeric insulator would have been obvious to one of ordinary skill in the art because insulating layers are known to be made of both polymeric and non-polymeric materials, such as silicon dioxide, are commonly known generic materials used as insulating layers. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Lastly, AAPA fails to teach the stud bump contains Cu.

While Shibata, which teaches the use of gold (Au) bumps (7, 45+), fails to teach the stud bump comprises Cu, it would have been obvious to one of ordinary skill in the art at the time of the invention to use Cu in the invention of Shibata because Au and Cu are materials known to a skilled artisan to be equivalent. Both are well known in the art materials used as bumps, as taught by Tummala et al., *Microelectronics Packaging Handbook: Semiconductor Packaging - Part II*, 1997, pp II- 207. The substitution of one known equivalent technique for another may be obvious even if the prior art does not expressly suggest the substitution (Ex parte Novak 16 USPQ 2d 2041 (BPAI 1989); In re Mostovych 144 USPQ 38 (CCPA 1964); In re Leshin 125 USPQ 416 (CCPA 1960);

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Graver Tank & Manufacturing Co. V. Linde Air Products Co. 85 USPQ 328 (USSC 1950).

With respect to claim 56, Shibata teaches the adhesive material comprises an anisotropic conductive film, an anisotropic conductive paste, or an isotropic conductive paste (7, 64+).

As to claim 57, Shibata, which teaches the bump is made of gold (7, 45+), teaches the package does not contain any solder paste.

With respect to claim 58, while AAPA fails to teach the insulating layer comprises silicon nitride, silicon oxide, or silicon oxynitride, it would have been obvious to one of ordinary skill in the art at the time of the invention to use silicon nitride, silicon oxide, or silicon oxynitride as the insulating layer in the invention of AAPA because they are conventionally known and used insulating layers known to each and every skilled artisan. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

As to claim 59, while AAPA fails to teach there is no under bump metal under the stud bump, it would have been obvious to one of ordinary skill in the art at the time of the invention to remove the UBM of AAPA because the omission of an element and its function is obvious if the function of the element is not desired (MPEP 2144.04 IIA). The device would work without the UBM, therefore it would be obvious to remove it and its desired function in order to reduce cost.

Regarding claim 60, AAPA, Shibata and Kaneda fail to teach the stud bump is formed by wire bonding a Pd coated copper wire to the RDL pattern using a capillary to provide the stud bump with a coined shape.

Please note that using by wire bonding a Pd coated copper wire to the RDL pattern using a capillary to provide the stud bump is a process limitation is a product claim and therefore isn't given any patentable weight. Even though product-by-process claims are limited by and defined by the process, determination of patentability is based on the product itself. The patentability of a product does not depend on its method of production. If the product in the product-by-process claim is the same as or obvious from a product of the prior art, the claim is unpatentable even though the prior product was made by a different process." In re Thorpe, 777 F.2d 695, 698, 227 USPQ 964, 966 (Fed. Cir. 1985)

Further, relating to the coined shape, while Shibata fails to teach the stud bump is a coined stud bump, it would have been obvious to one of ordinary skill in the art at the time of the invention to use a coined stud bump in the invention of Shibata because the use of a stud bump or a coined stud bump are equivalent. A skilled artisan knows that each are commonly known and used bumps to interconnect a die to a substrate, as taught by Lau, Flip Chip Technologies, 1996, pp. 129-131. The substitution of one known equivalent technique for another may be obvious even if the prior art does not expressly suggest the substitution (Ex parte Novak 16 USPQ 2d 2041 (BPAI 1989); In re Mostovych 144 USPQ 38 (CCPA 1964); In re Leshin 125 USPQ 416 (CCPA 1960);

Graver Tank & Manufacturing Co. V. Linde Air Products Co. 85 USPQ 328 (USSC 1950).

Claims 61, and 63-66 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Admitted Prior Art (hereafter AAPA) Figures 1-3, in view of Shibata, US Patent 6,461,890.

AAPA teaches a wafer-level chip scale package, comprising:

- a substrate [5] containing an integrated circuit [40];
- a re-distributed line (RDL) pattern [20] on the substrate and the integrated circuit;
- an insulating layer [25] covering a portion of the RDL pattern;
- a non-reflowed stud bump [35] located on the portion of the RDL pattern not covered by the insulating layer.

AAPA fails to teach a leadframe substrate containing a bond pad; and
an adhesive material containing conductive particles located between the chip and the substrate.

Shibata (Figures 5 & 6) teaches:

- a chip [10] containing a stud bump [11];
- a leadframe substrate [60] containing a bond pad [61]; and
- an adhesive material [30] containing conductive particles [32] located between the chip and the substrate.

It would have been obvious to one of ordinary skill in the art at the time of the invention to use the leadframe with the claimed conductive adhesive because it is conventionally known in the art to connect a chip to a leadframe using a conductive

adhesive. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Lastly, AAPA, and Shibata fail to teach the insulating layer comprises a non-polymeric dielectric material.

AAPA is silent as to the specific material used as the insulating layer that covers the RDL, the use of a non-polymeric insulator would have been obvious to one of ordinary skill in the art because insulating layers are known to be made of both polymeric and non-polymeric materials, such as silicon dioxide, are commonly known generic materials used as insulating layers. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Please note that while AAPA fails to specifically teach the stud bump is non-reflowed, it would have been obvious to one of ordinary skill in the art that the bump would have non-reflowed at the time of deposition and then later reflowed. Therefore, there was a point in the process wherein the stud bump was non-reflowed. This rejection relies upon that moment in time.

Regarding claim 63, Shibata teaches the adhesive material comprises an anisotropic conductive film, an anisotropic conductive paste, or an isotropic conductive paste (7, 64+).

As to claim 64, Shibata, which teaches the bump is made of gold (7, 45+), teaches the package does not contain any solder paste.

In re claim 65, while Shibata, which teaches the use of gold (Au) bumps (7, 45+), fails to teach the stud bump comprises Cu, it would have been obvious to one of

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ordinary skill in the art at the time of the invention to use Cu in the invention of Shibata because Au and Cu are materials known to a skilled artisan to be equivalent. Both are well known in the art materials used as bumps, as taught by Tummala et al., Microelectronics Packaging Handbook: Semiconductor Packaging - Part II, 1997, pp II-207. The substitution of one known equivalent technique for another may be obvious even if the prior art does not expressly suggest the substitution (Ex parte Novak 16 USPQ 2d 2041 (BPAI 1989); In re Mostovych 144 USPQ 38 (CCPA 1964); In re Leshin 125 USPQ 416 (CCPA 1960); Graver Tank & Manufacturing Co. V. Linde Air Products Co. 85 USPQ 328 (USSC 1950).

As to claim 66, while AAPA fails to teach there is no under bump metal under the stud bump, it would have been obvious to one of ordinary skill in the art at the time of the invention to remove the UBM of AAPA because the omission of an element and its function is obvious if the function of the element is not desired (MPEP 2144.04 IIA). The device would work without the UBM, therefore it would be obvious to remove it and its desired function in order to reduce cost.

Claim 62 is rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Admitted Prior Art (hereafter AAPA) Figures 1-3, in view of Shibata, US Patent 6,461,890, as applied to claim 61 above, and further in view of Kaneda et al., US Patent 6,223,429.

AAPA and Shibata fail to teach the conductive particles comprise metal with an insulating layer.

Kaneda (6, 35+) teaches the conductive particles comprise metal with an insulating layer.

It would have been obvious to one of ordinary skill in the art at the time of the invention to use the conductive particles of Kaneda in the invention of Shibata because Kaneda teaches conductive particles comprising metal with an insulating layer improves insulating properties in the lateral direction of metal particles (6, 35+).

Claims 67-72 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Admitted Prior Art (hereafter AAPA) Figures 1-3, in view of Shibata, US Patent 6,461,890 and Kaneda et al., US Patent 6,223,429.

AAPA teaches an electronic apparatus containing a packaged semiconductor device without solder paste, comprising:

- a substrate [5] containing a chip pad [40];
- a re-distributed line (RDL) pattern [20] on the chip pad;
- an insulating layer [25] covering a portion of the RDL pattern;
- a stud bump [35] located on the portion of the RDL pattern not covered by the insulating layer.

AAPA fails to teach a leadframe substrate containing a bond pad; and
an adhesive material containing conductive particles located between the chip and the substrate with at least one conductive particle contacting both the stud bump and the bond pad.

Shibata (Figures 5 & 6) teaches:

- a chip [10] containing a stud bump [11];

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a leadframe substrate [60] containing a bond pad [61]; and
an adhesive material [30] containing conductive particles [32] located between the chip and the substrate with at least one conductive particle contacting both the stud bump and the bond pad.

It would have been obvious to one of ordinary skill in the art at the time of the invention to use the leadframe with the claimed conductive adhesive because it is conventionally known in the art to connect a chip to a leadframe using a conductive adhesive. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Further, AAPA and Shibata fail to teach the conductive particles comprise metal with an insulating layer.

Kaneda (6, 35+) teaches the conductive particles comprise metal with an insulating layer.

It would have been obvious to one of ordinary skill in the art at the time of the invention to use the conductive particles of Kaneda in the invention of Shibata because Kaneda teaches conductive particles comprising metal with an insulating layer improves insulating properties in the lateral direction of metal particles (6, 35+).

Also, AAPA, Shibata and Kaneda fail to teach the insulating layer comprises a non-polymeric dielectric material.

AAPA is silent as to the specific material used as the insulating layer that covers the RDL, the use of a non-polymeric insulator would have been obvious to one of ordinary skill in the art because insulating layers are known to be made of both

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polymeric and non-polymeric materials, such as silicon dioxide, are commonly known generic materials used as insulating layers. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Lastly, AAPA fails to teach the stud bump contains Cu.

While Shibata, which teaches the use of gold (Au) bumps (7, 45+), fails to teach the stud bump comprises Cu, it would have been obvious to one of ordinary skill in the art at the time of the invention to use Cu in the invention of Shibata because Au and Cu are materials known to a skilled artisan to be equivalent. Both are well known in the art materials used as bumps, as taught by Tummala et al., *Microelectronics Packaging Handbook: Semiconductor Packaging - Part II*, 1997, pp II- 207. The substitution of one known equivalent technique for another may be obvious even if the prior art does not expressly suggest the substitution (*Ex parte Novak* 16 USPQ 2d 2041 (BPAI 1989); *In re Mostovych* 144 USPQ 38 (CCPA 1964); *In re Leshin* 125 USPQ 416 (CCPA 1960); *Graver Tank & Manufacturing Co. V. Linde Air Products Co.* 85 USPQ 328 (USSC 1950).

Regarding claim 68, Shibata teaches the adhesive material comprises an anisotropic conductive film, an anisotropic conductive paste, or an isotropic conductive paste (7, 64+).

As to claims 69 and 72, Shibata, which teaches the bump is made of gold (7, 45+), teaches the package does not contain any solder paste.

With respect to claim 70, while AAPA fails to teach the insulating layer comprises silicon nitride, silicon oxide, or silicon oxynitride, it would have been obvious to one of

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ordinary skill in the art at the time of the invention to use silicon nitride, silicon oxide, or silicon oxynitride as the insulating layer in the invention of AAPA because they are conventionally known and used insulating layers known to each and every skilled artisan. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

As to claim 71, while AAPA fails to teach there is no under bump metal under the stud bump, it would have been obvious to one of ordinary skill in the art at the time of the invention to remove the UBM of AAPA because the omission of an element and its function is obvious if the function of the element is not desired (MPEP 2144.04 IIA). The device would work without the UBM, therefore it would be obvious to remove it and its desired function in order to reduce cost.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to David A. Zarneke whose telephone number is (571)-272-1937. The examiner can normally be reached on M-Th 7:30 AM-6 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, William Baumeister can be reached on (571)-272-1722. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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